

Technology Options for Photo-voltaic Solar Cells

Claudio Fiegna

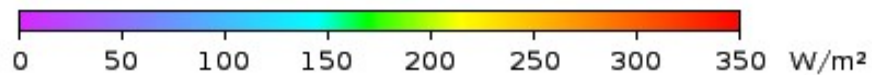
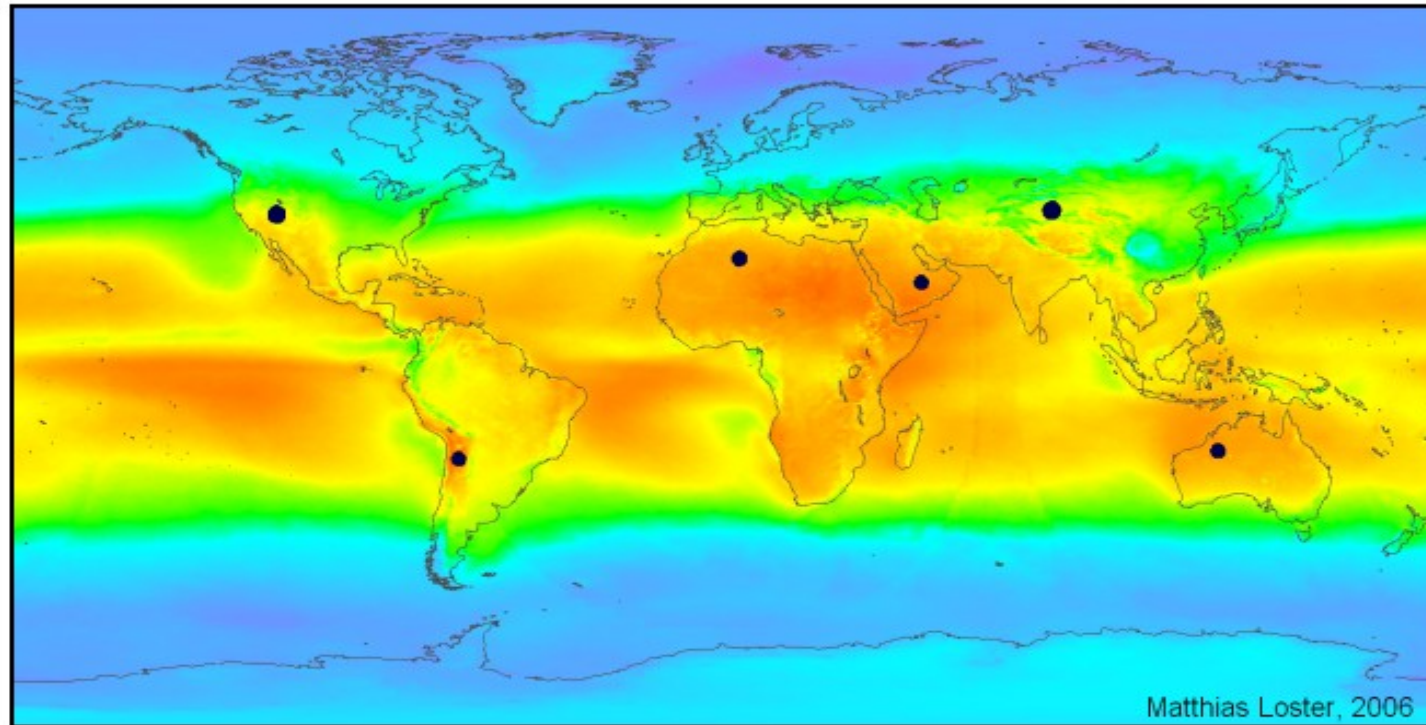
Outline

- Introduction
- Working principle for solar cells
- Silicon based solar cells
 - Crystalline
 - Thin film a-Si or $\mu\text{c-Si}$
- Other thin-film technologies
- Organic solar cells

Solar Energy and Photo-voltaic conversion

- La potenza che colpisce l'atmosfera terrestre è di circa $170 \cdot 10^{15}$ Watt (170 PW).
- In meno di un'ora il sole invia sulla Terra una quantità di energia pari all'intero consumo complessivo mondiale annuale.
- Il flusso di energia solare è molto diluito ed intermittente
- La conversione fotovoltaica sfrutta il meccanismo di generazione di carica elettrica prodotto dalla radiazione luminosa in un materiale semiconduttore

Solar Energy and Photo-voltaic conversion



$\Sigma \bullet = 18 \text{ TWe}$

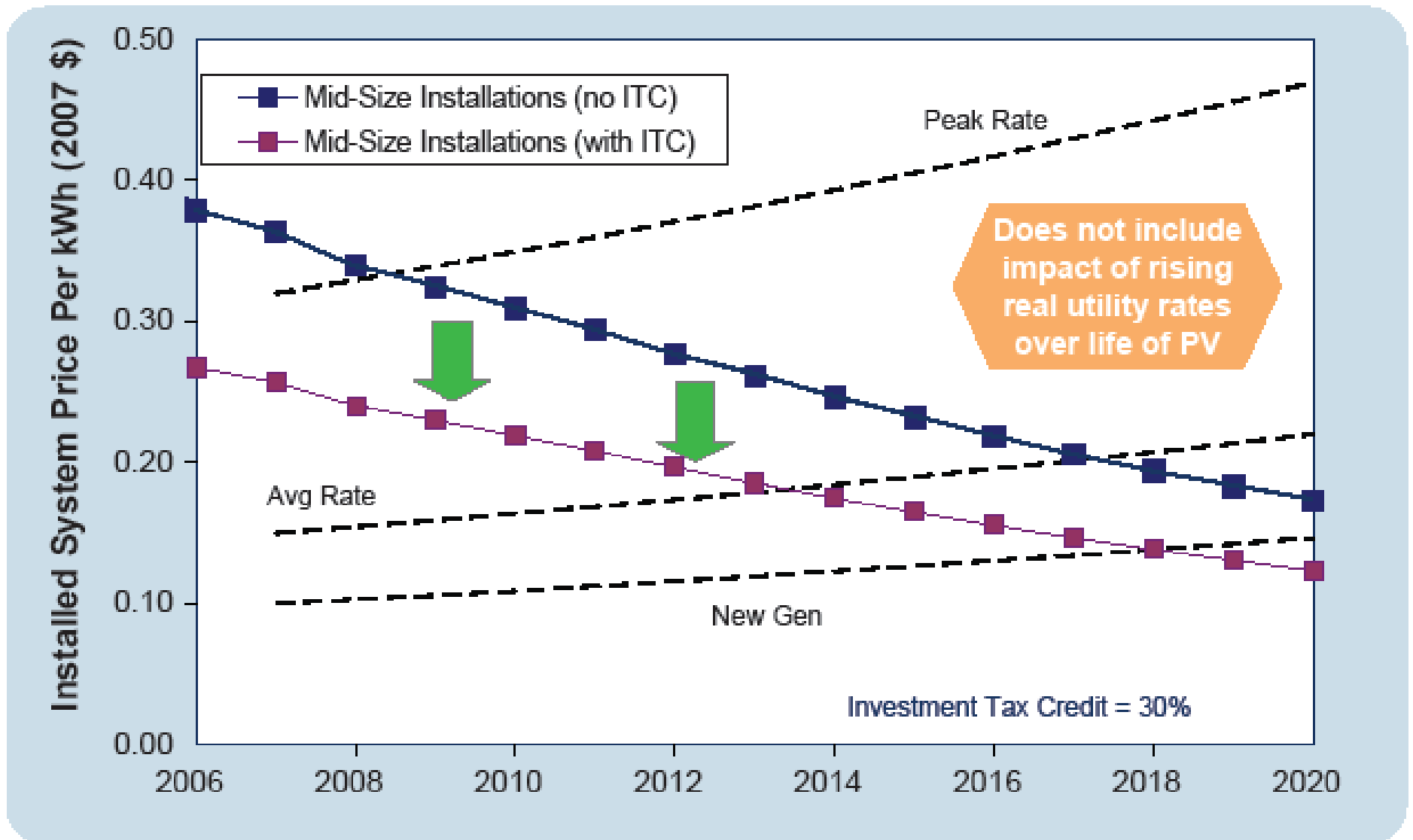
Development of PV technology

- The photovoltaic (PV) effect was discovered in 1839 by Edmond Becquerel
- After the introduction of silicon as the prime semiconductor material in the late 1950s, silicon PV diodes became available; main applications: TLC equipments in remote locations and satellites
- The oil crisis of 1973 led to public investments for technology development
- Since the beginning of the 1990s, ecological considerations acted as a main driving force in promoting PV solar energy

Global Status of Solar Photovoltaics

- By the end of 2007, the cumulative installed capacity of solar photovoltaic (PV) systems around the world had reached more than 9,200 MW. (1,200 MW at the end of 2000).
- Installations of PV cells and modules around the world have been growing fast
- solar electricity industry that it is now worth more than an annual € 13 billion
- The cost of PV electricity is decreasing steadily

Equivalent PV Electricity Cost (CA)



Assumptions:

PV Cost reduction past 2010 = 8% per year

CA 2007 base utility rates, increase = 3% per year

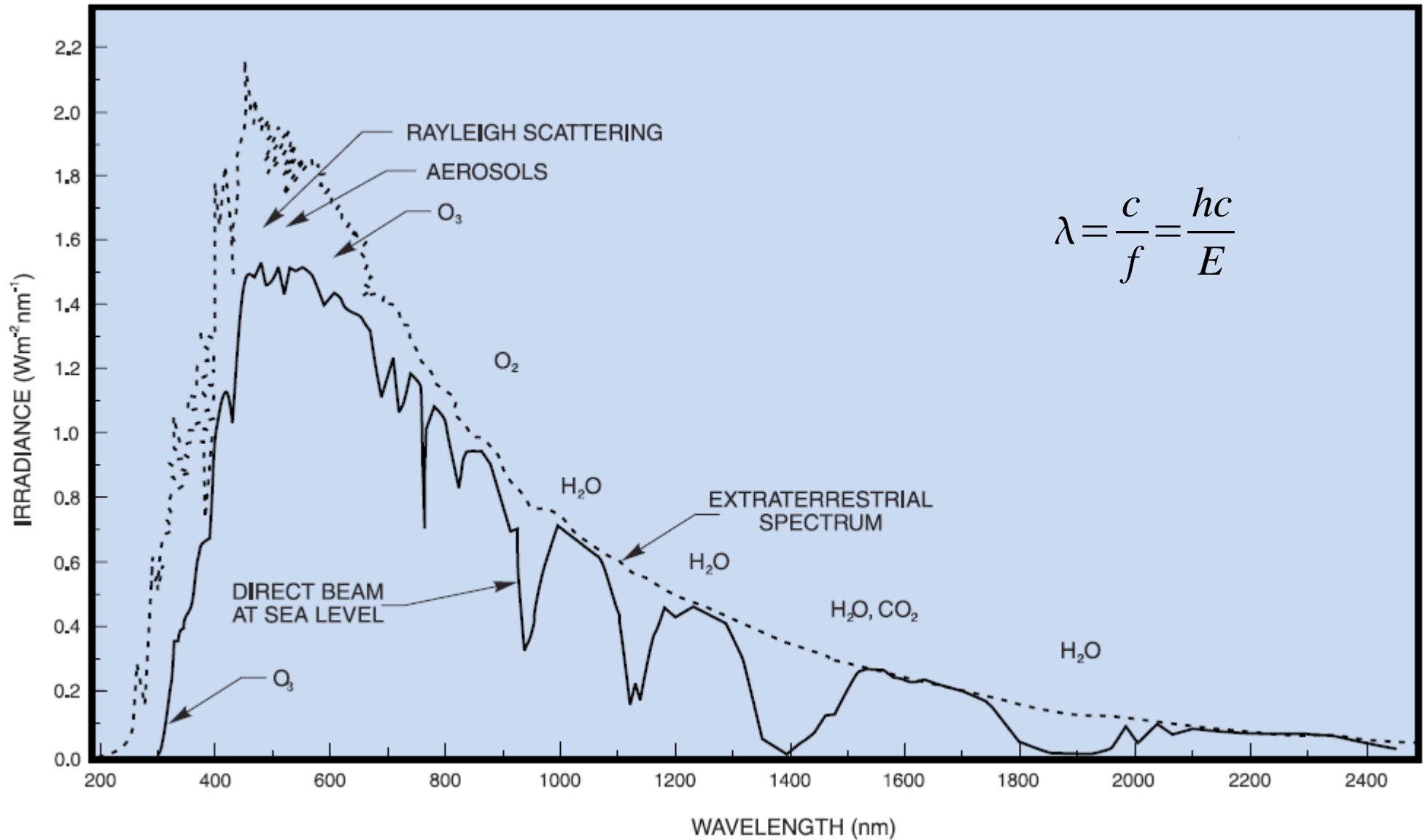
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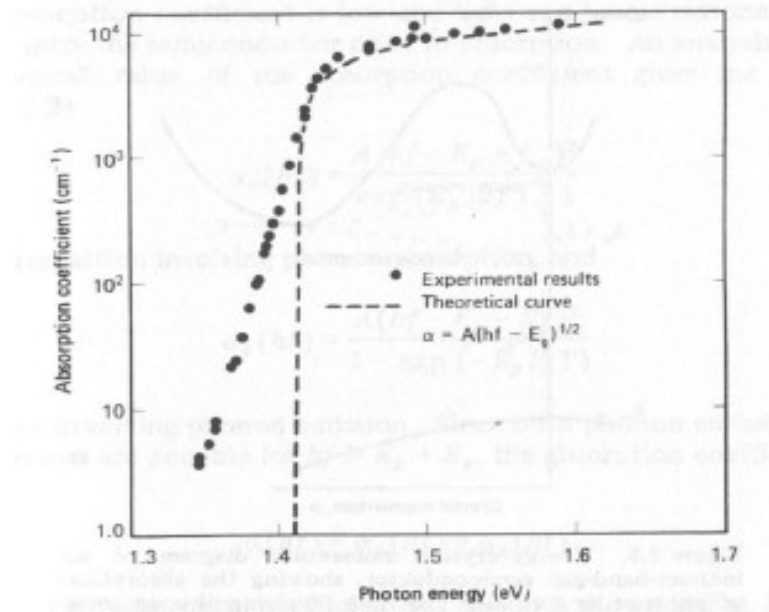
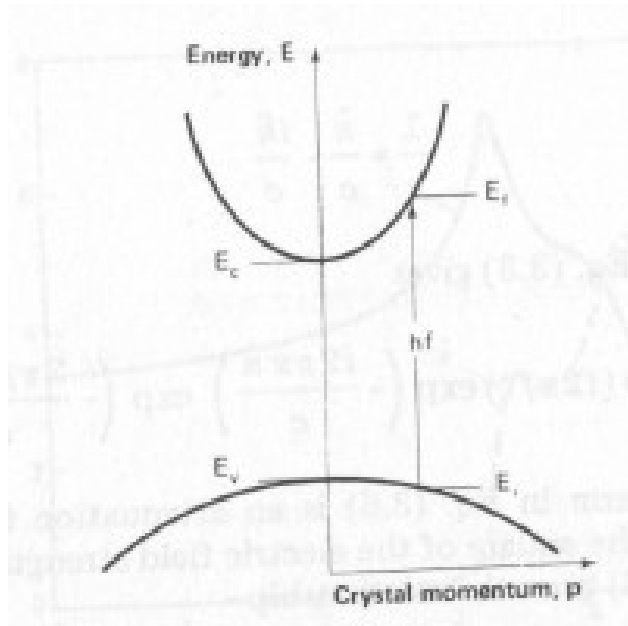
Interaction of light with semiconductors

- When light strikes the surface of a semiconductor it is partially transmitted and partially reflected;
- The transmitted light is absorbed by the semiconductor;
- The energy associated to absorbed light promotes the transition of electrons from occupied states (e.g. valence band) to the higher-energy unoccupied states (conduction band).

Solar spectrum



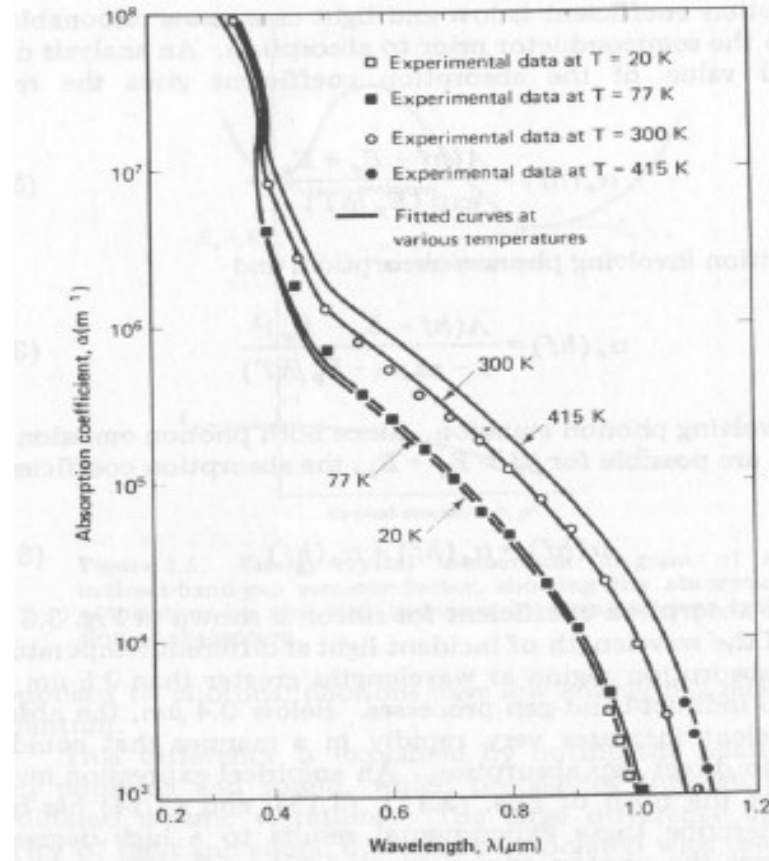
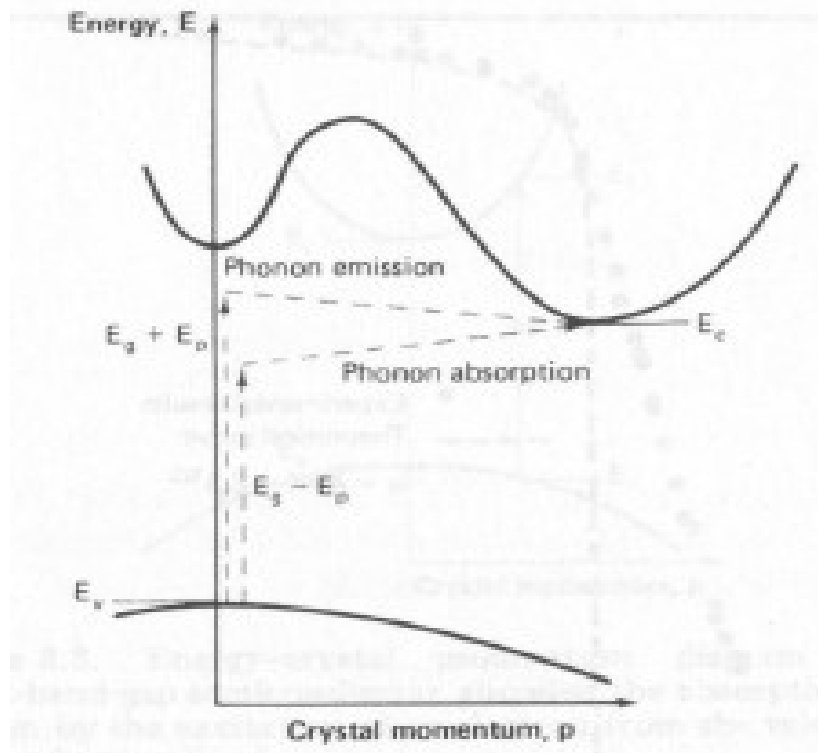
Absorption of light in semiconductors



M.A. Green, "Solar Cells", Univ. South Wales.

Absorption of light in a direct-bandgap semiconductor (right) and absorption coefficient as a function of photon energy in GaAs.

Absorption of light in semiconductors



$$\lambda = \frac{c}{f} = \frac{hc}{E}$$

M.A. Green, "Solar Cells", Univ. South Wales.

Absorption of light in an indirect-bandgap semiconductor (right) and absorption coefficient as a function of photon wavelength in Silicon.

Other absorption mechanisms

- Phonon-assisted absorption in indirect-gap semiconductors;
- free-carrier absorption (no electro-hole generation)
- two-steps absorption through an energy level within the bandgap
- electric-field assisted sub-bandgap absorption
- effects of bandgap narrowing at large doping levels

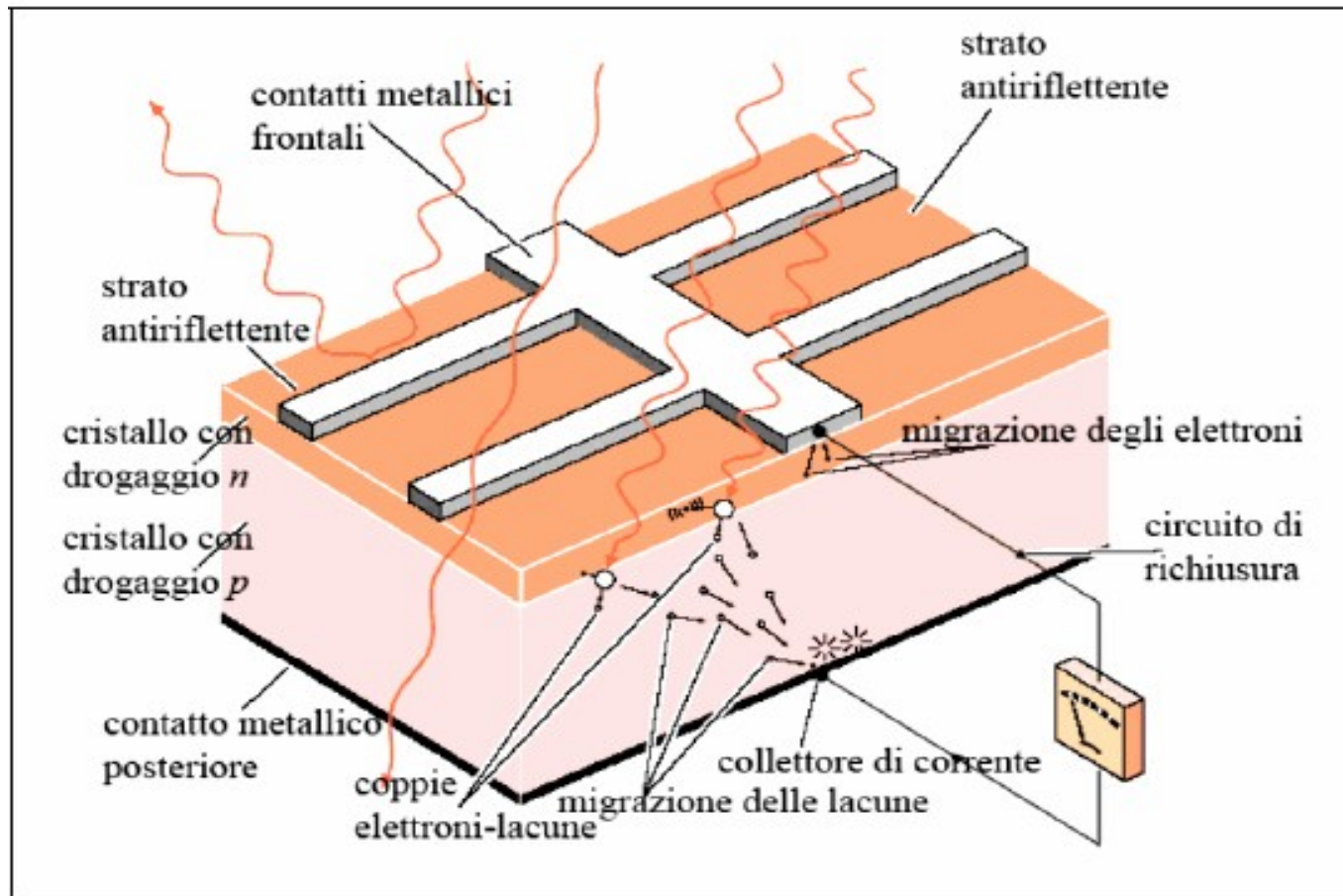
Light absorption (normal flux)

- $F(x)$: photon flux - number of photons crossing the unit-area per unit-time [$\text{cm}^{-2} \text{s}^{-1}$]
- $\alpha(x)$: absorption coefficient [cm^{-1}]
- Optical generation rate: $G_{\text{OPT}} = \alpha(x)F(x)$
- $\alpha(x)F(x)dx$: number of absorptions per unit time within dx
- $dF(x) = -\alpha(x)F(x)dx$
- Let $\alpha(x) = \text{const}$; let x_0 be a reference abscissa (eg. Surface) $\rightarrow F(x) = F(x_0) \exp[-(x-x_0)\alpha]$

Solar cells

- Basic requirements for solar-cell operation:
 - optical generation of electron-hole pairs under sun illumination: the band-gap must correspond to wavelength included in the spectrum of solar light.
 - Built-in electric field for separation of carriers.
 - low recombination rate – low defect density.

Cella fotovoltaica convenzionale al silicio



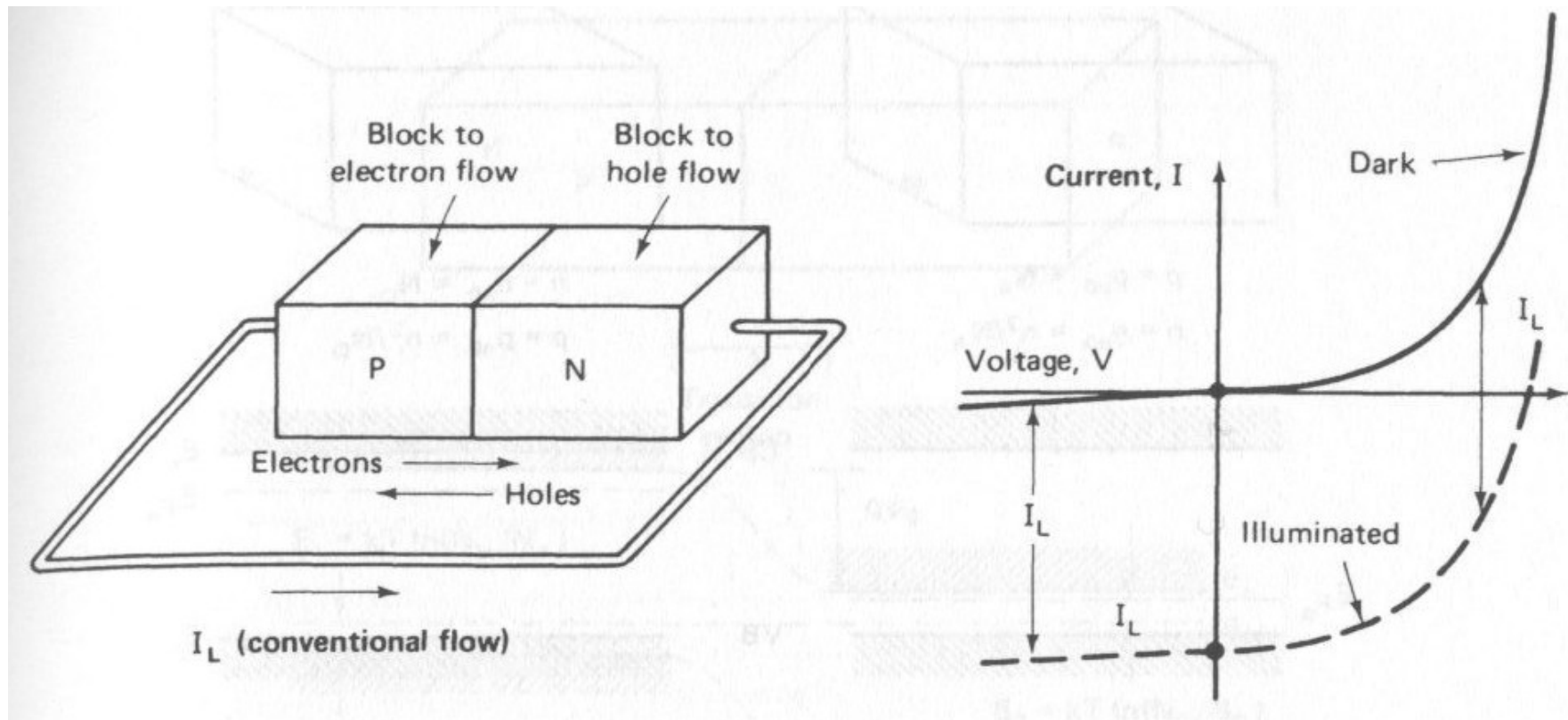
Efficienza di conversione: 16% - 20%

Massimo teorico: 31%

Tecnologie alternative:

- Film sottile silicio amorfo (7% - 9%)
- Celle multi-giunzione (fino a 40%)
- Celle in materiale organico (basso costo, bassa efficienza 5%)

The PN junction as a solar cell



M.A. Green, "Solar Cells", Univ. South Wales.

Photo-generated carriers surviving recombination and separated by the junction field contribute a negative current $-I_L$ that (approximately) superimposes to the conventional I-V characteristic.

The PN junction as a solar cell

- Under the simplifying assumption of uniform optical generation rate G_{OPT}

- Neutral region in region N:
$$\frac{d^2 \Delta p}{dx^2} = \frac{\Delta p}{L_h^2} - \frac{G}{D_h}$$

- performing the same derivation as in the “dark” case

$$J_h(x) = \frac{qD_h p_{n0}}{L_h} (e^{qV/kT} - 1) e^{-x/L_h} - qGL_h e^{-x/L_h}$$

- Optical generation in the depletion region:

$$|\delta J_e| = |\delta J_h| = qGW$$

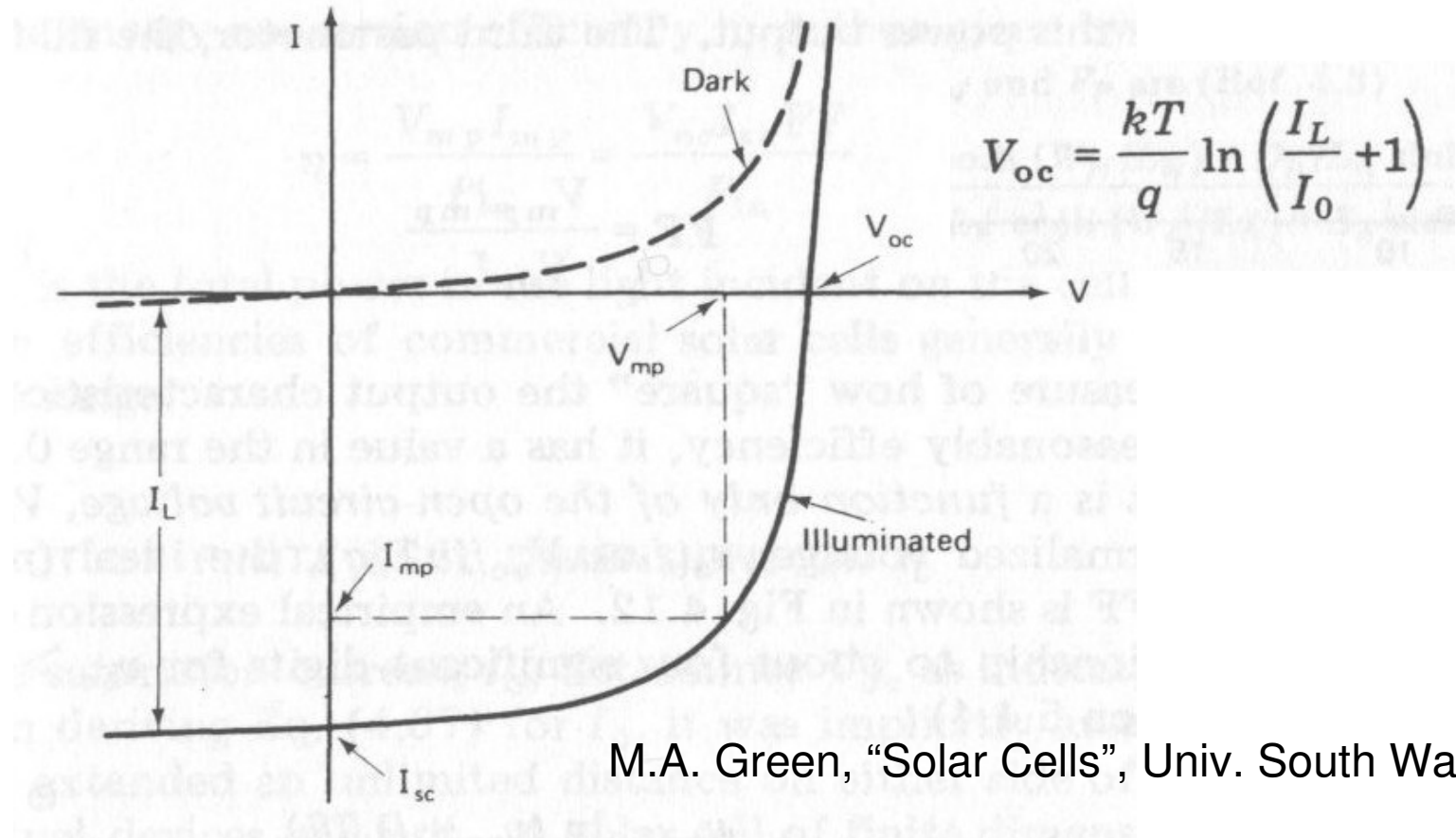
- repeating for electrons at the P side and combining results:

$$I = I_0 (e^{qV/kT} - 1) - I_L$$

$$I_L = qAG(L_e + W + L_h)$$

- the photo-generated current is contributed by the depletion region plus two adjacent regions within a diffusion length on each side

PN junction solar cell



$$FF = \frac{V_{mp} I_{mp}}{V_{oc} I_{sc}}$$

$$\eta = \frac{V_{mp} I_{mp}}{P_{in}} = \frac{V_{oc} I_{sc} FF}{P_{in}}$$

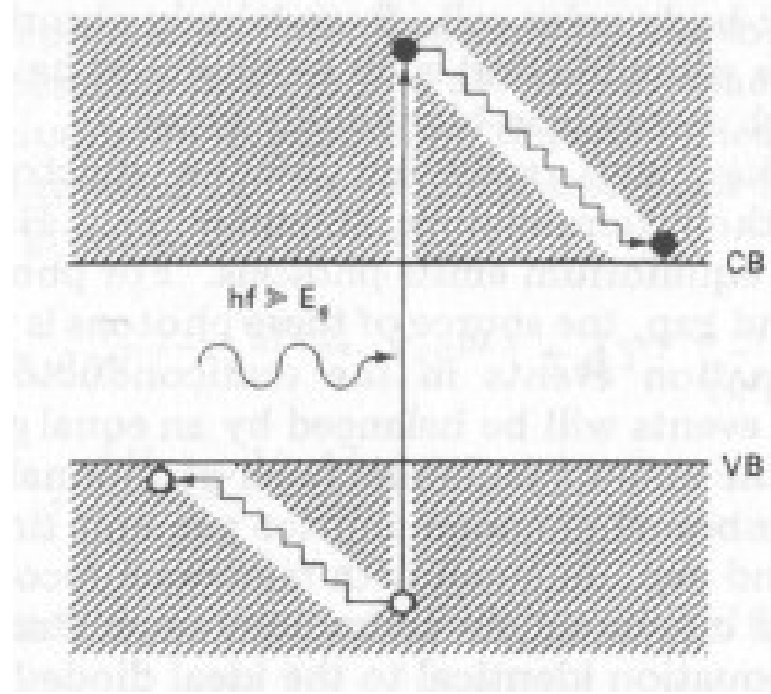
Conversion Efficiency

- Efficiency requires:
 - large open-circuit voltage V_{OC}
 - Low saturation current I_0 (dark I-V charact.)
 - Large short-circuit current I_{SC}
- Low I_0 --> low recombination rates
- Large I_{SC} --> small band-gap (downside: energy wasted into heat generation).

Loss mechanisms

- Non absorption ($E_{ph} < E_g$)
- Thermalization ($E_{ph} > E_g$)
- Optical Losses (Reflection, Transmission, Area Loss)
- Collection Losses (Recombination)
 - Bulk Recombination
 - Surface Recombination
 - Mid Gap States (Dangling Bonds) in Amorphous materials

Fundamental energy losses limiting efficiency

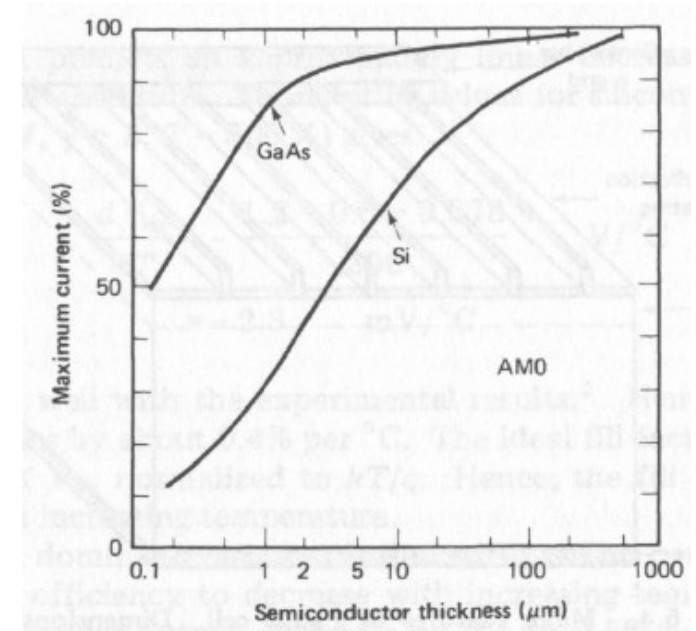
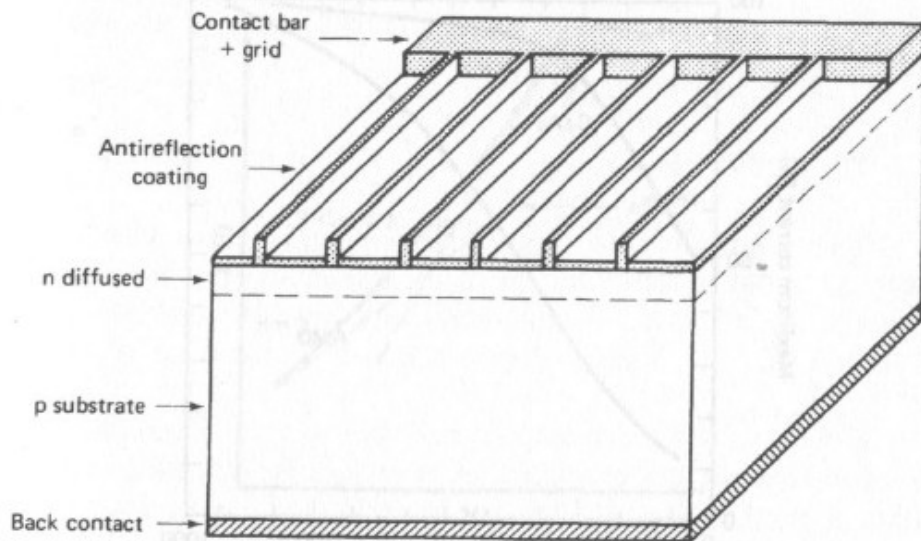


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- For high-energy photons, the energy in excess of the bandgap is lost through phonon emission (heating).
- Although the carriers are separated in energy by a bandgap, V_{OC} is limited to a fraction of E_G/q .

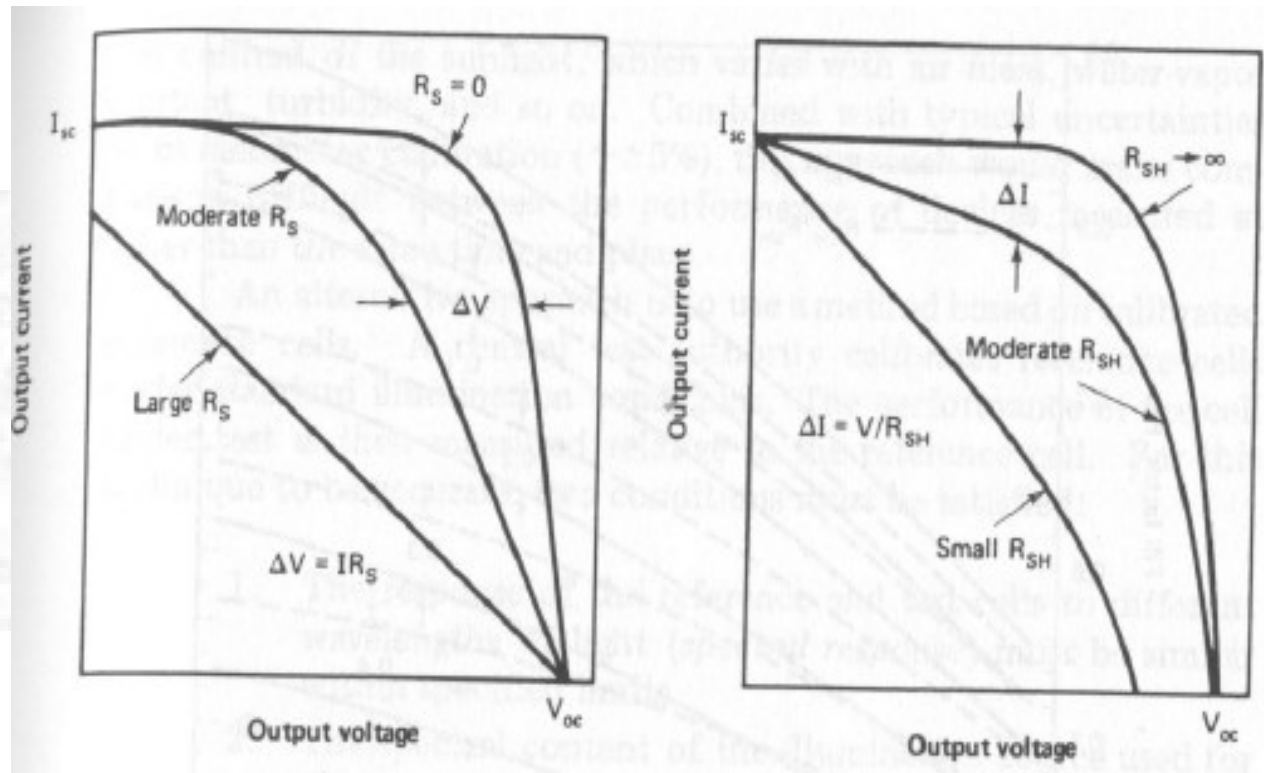
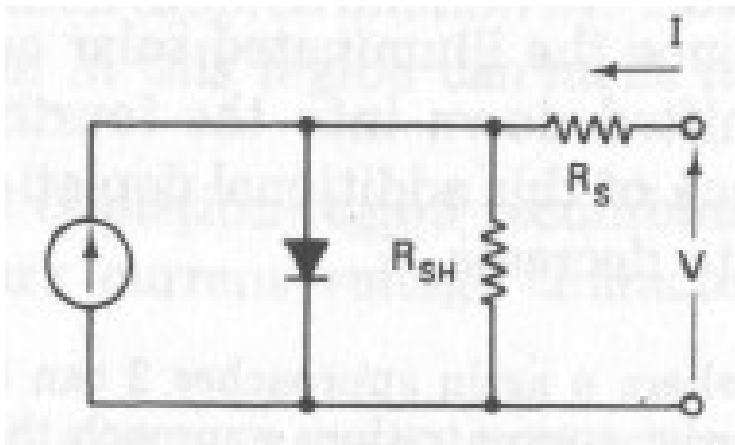
Extrinsic energy losses

- The surface of the cell is partially reflective; anti-reflective coating reduces reflection to 10%
- Electrical contacts on the exposed surface blocks 5%-10% of the incoming light
- If the cell is too thin, part of the light may not be absorbed



Extrinsic energy losses

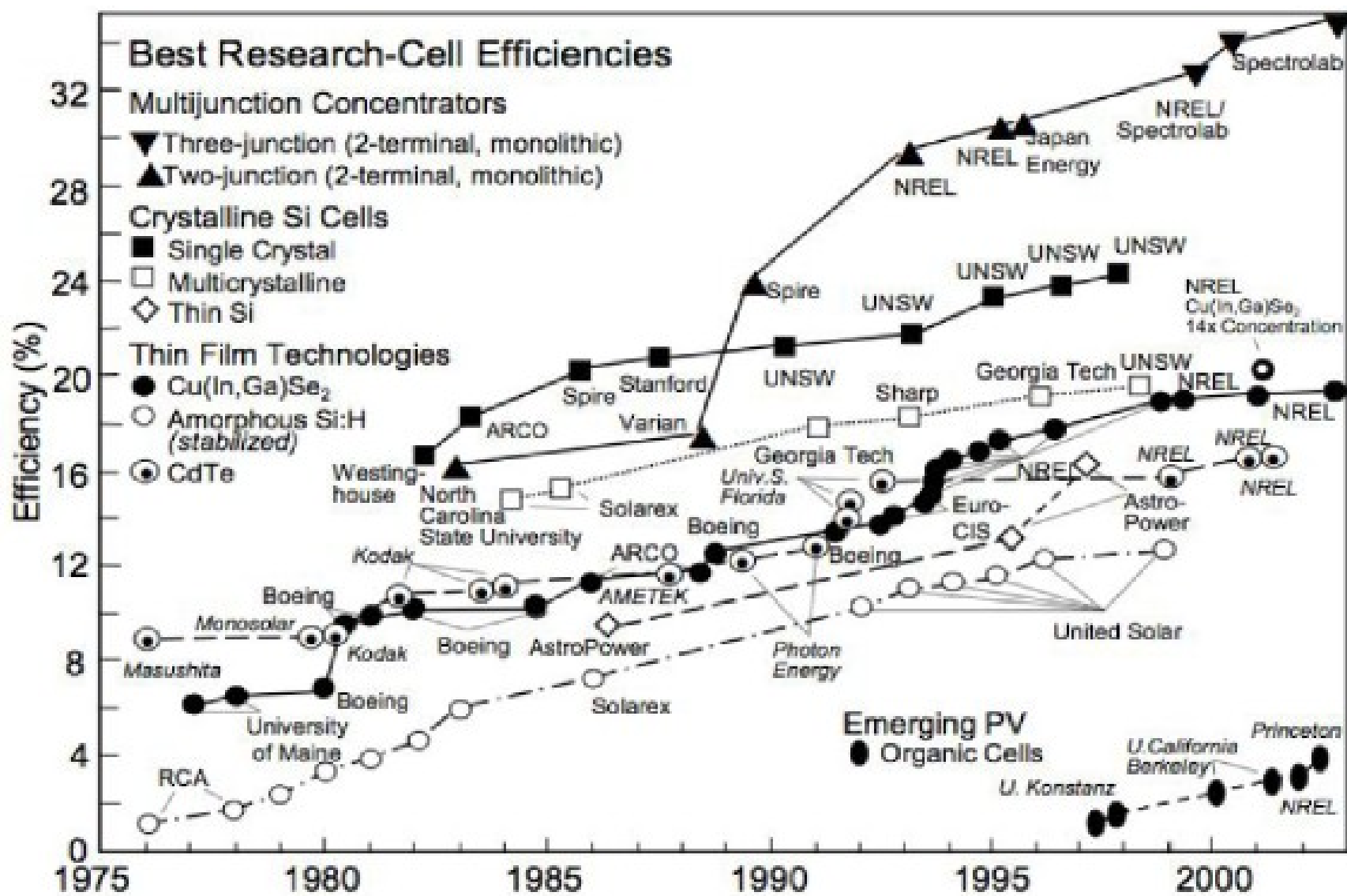
- Recombination in bulk silicon and at the surfaces limits V_{OC}
- The fill factor is degraded by parasitic series and shunt resistances



Main technology options

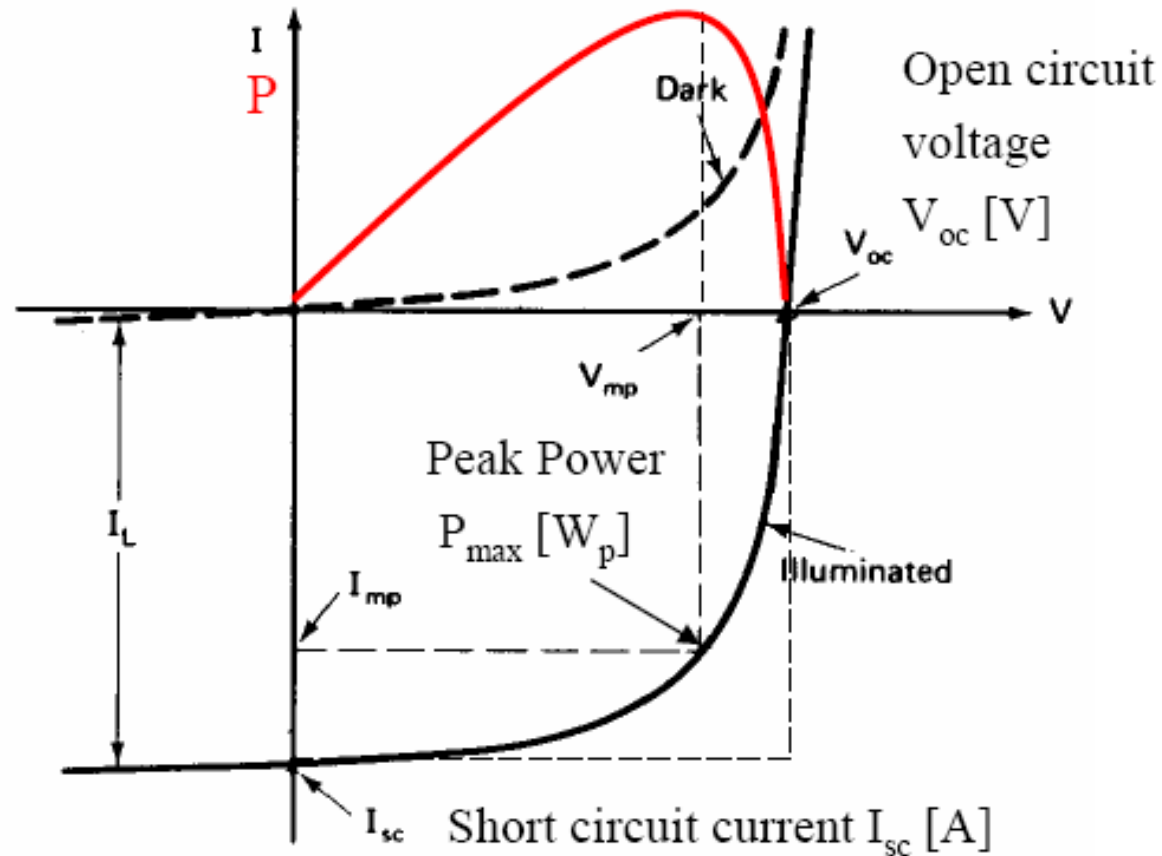
- Crystalline Silicon PV cells; effic.: 16% - 20%
- Thin film cells (7% - 10%)
 - Silicon based
 - CdS/CIS
 - Cds/CdTe
- Organic Cells (5%)
- Concentrator PV cells

Best Solar Cells Efficiencies



Theoretical Limits of photovoltaic conversion

Performance parameters



$$\eta = \frac{P_{max}}{P_I} = FF \cdot V_{oc} \cdot \frac{I_{sc}}{P_I}$$

$$P_{max} = V_{mp} \cdot I_{mp} = FF \cdot V_{oc} \cdot I_{sc}$$

Solar cell performance

- **Optimal design keys:**
 - **High J_{sc}**
 - Minimize front surface reflection (ARC)
 - Minimize transmission losses (thick absorber)
 - Minimize surface recombination (passivation layers)
 - Minimize bulk recombination
 - large diffusion lengths
 - high electronic quality material
 - **Low I_0**
 - High doping densities
 - Low surface recombination velocities
 - Large diffusion lengths

Solar cell performance (P-n junction)

- **Short circuit current ($V=0$)**

$$I_{sc} = -I_L$$

- **Open circuit voltage ($I=0$)**

$$V_{oc} = \frac{KT}{q} \ln \left(\frac{I_L}{I_0} + 1 \right)$$

- **Saturation current**

$$I_0 = A \left(\frac{q D_n n_i^2}{L_n N_A} + \frac{q D_p n_i^2}{L_p N_D} \right)$$

Theoretical limits of energy conversion in solar cells

- Theoretical upper bounds of **efficiency** (η), **short circuit current** (J_{sc}) and **open circuit voltage** (V_{oc}) as a function of band gap energy and thickness of a material slab are investigated.
- We evaluate the relevance of losses due to:
 - recombination mechanisms
 - the absence of a light trapping strategy

Theoretical limits of energy conversion in solar cells

- ***AM1.5 Standard Global Spectrum*** with 100 mW/cm²
- Optical absorption coefficients $\alpha(E)$ and refractive indexes $n(E)$ for a-Si:H and c-Si from literature
- Accounted recombination mechanisms:
 - Auger and Radiative (c-Si)
 - Recombination on Dangling Bond (DB) states and Band Tails in a-Si:H

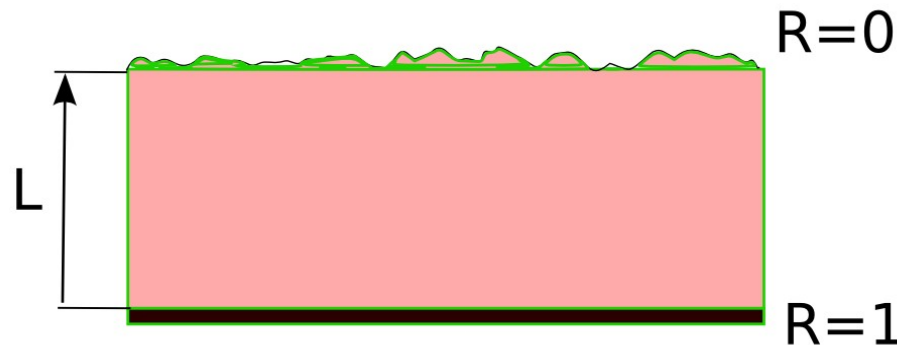
Absorbance

- **One-pass** (specular with no back reflector)



$$a(E) = 1 - \exp[-2\alpha(E)L]$$

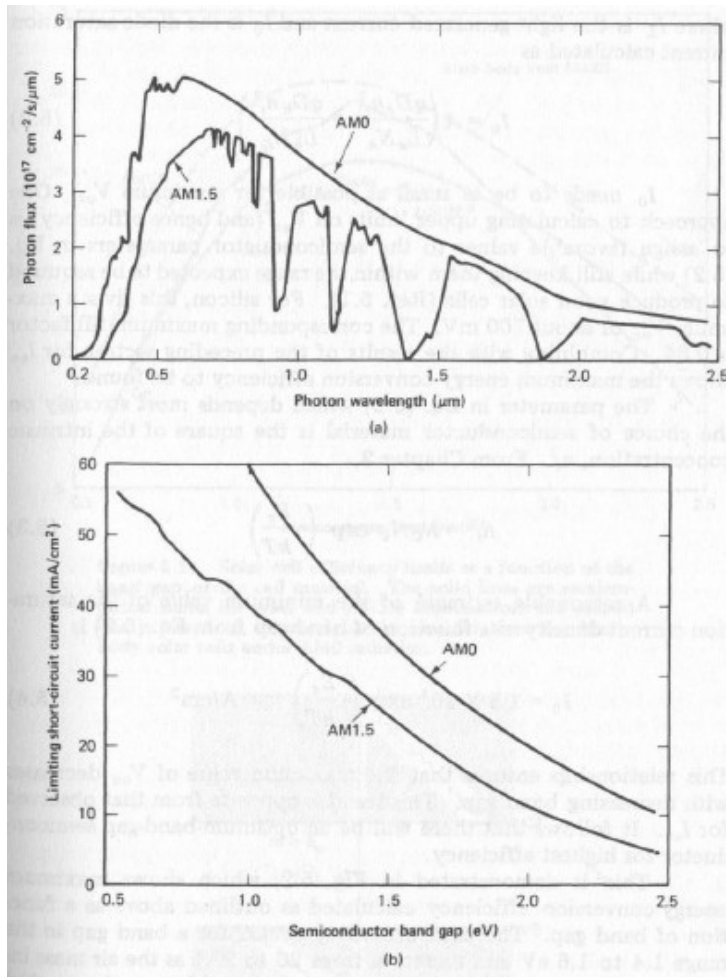
- **Lambertian** (randomized multiple scattering surfaces with back reflector)



$$a(E) = \frac{\alpha(E)}{\alpha(E) + \frac{1}{4n^2 L}}$$

- **Step function**: all photons with $E > E_g$ are absorbed and converted into electron-hole pairs; $a(E)=1$ if $E > E_g$.

Optical solar spectrum and maximum short-circuit current

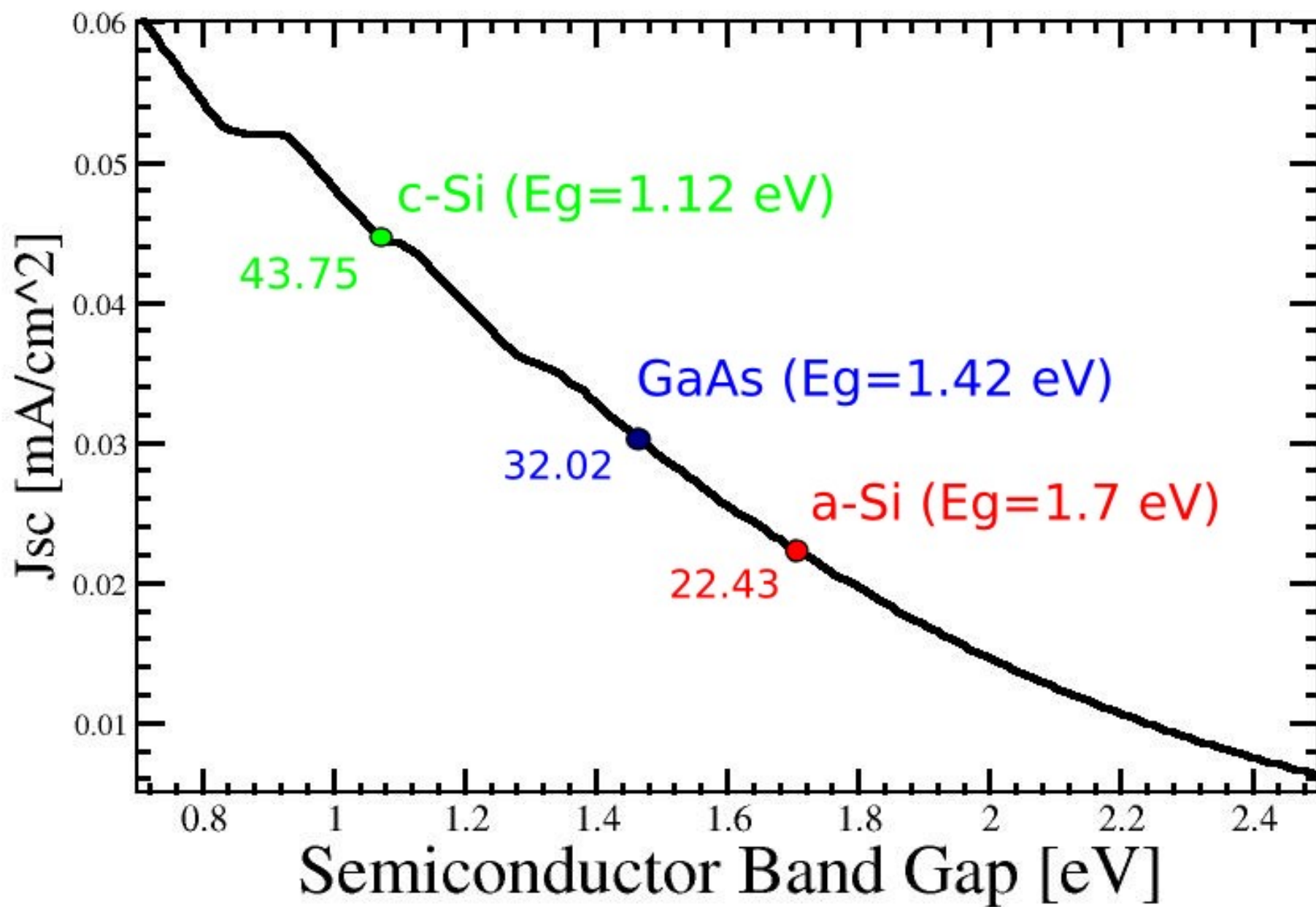


$$\lambda = \frac{c}{f} = \frac{hc}{E}$$

M.A. Green, "Solar Cells", Univ. South Wales.

Short-circuit current increases for decreasing bandgap (larger number of photons contribute to generation)

Limiting short-circuit current (AM1.5G)



Limit to the open-circuit voltage

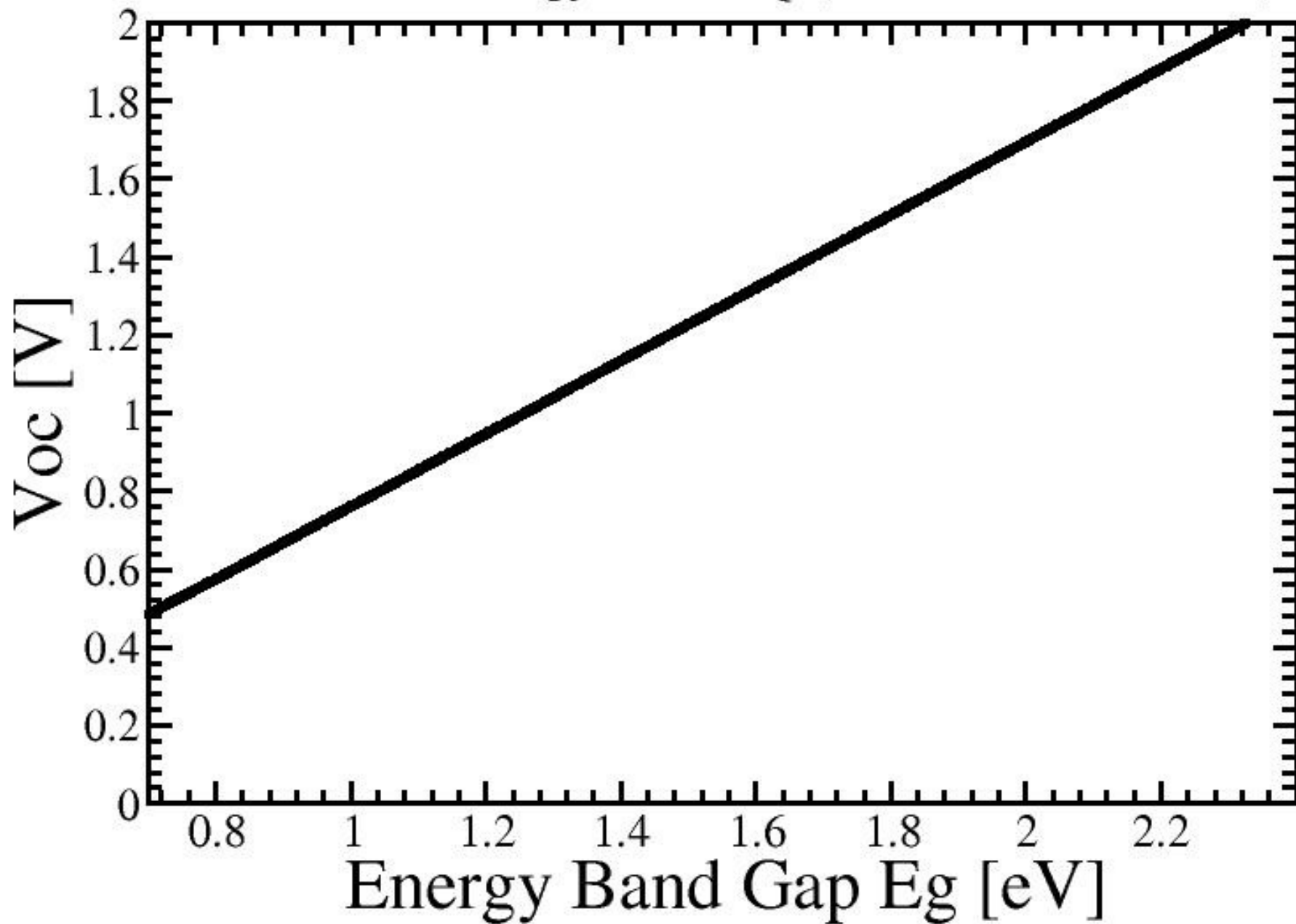
$$V_{oc} = \frac{kT}{q} \ln \left(\frac{I_L}{I_0} + 1 \right)$$

$$I_0 = A \left(\frac{qD_e n_i^2}{L_e N_A} + \frac{qD_h n_i^2}{L_h N_D} \right)$$

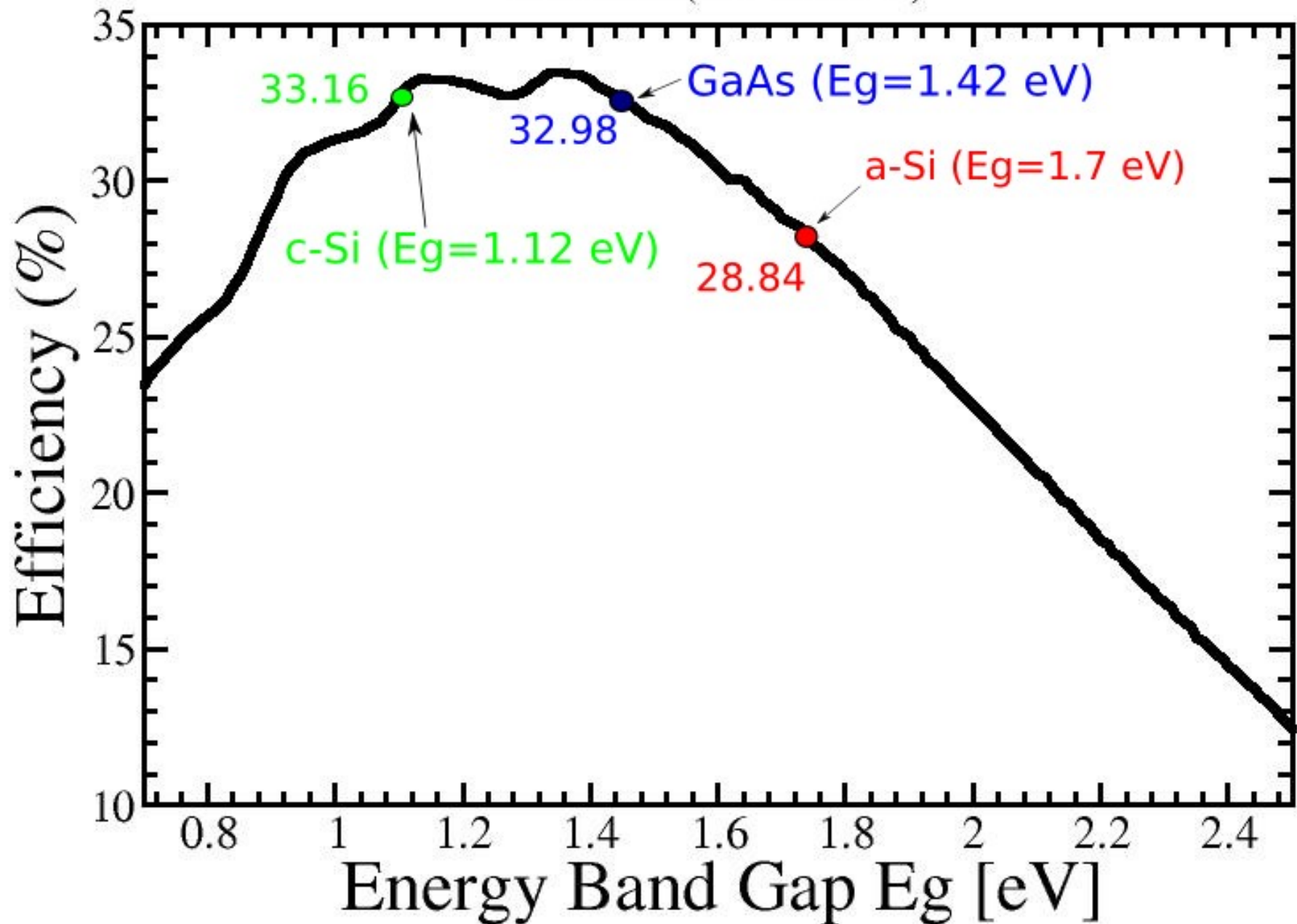
$$n_i^2 = N_C N_V \exp \left(- \frac{E_g}{kT} \right)$$

V_{OC} increases for low recombination rates (large diffusion lengths) and small intrinsic concentration (large bandgap)

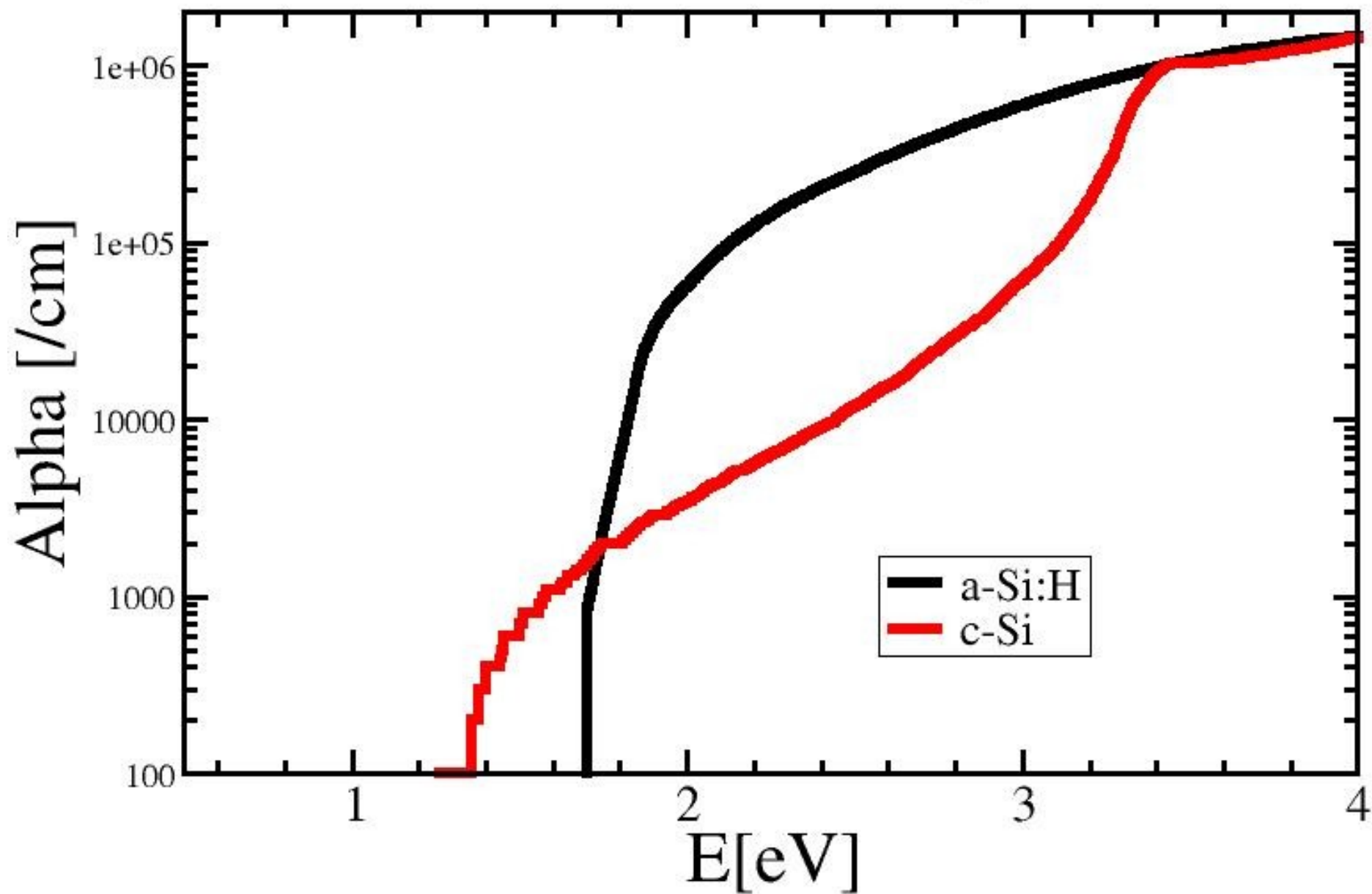
Open Circuit Voltage
as function of Energy Band Gap (AM1.5G 0.1 W/cm²)



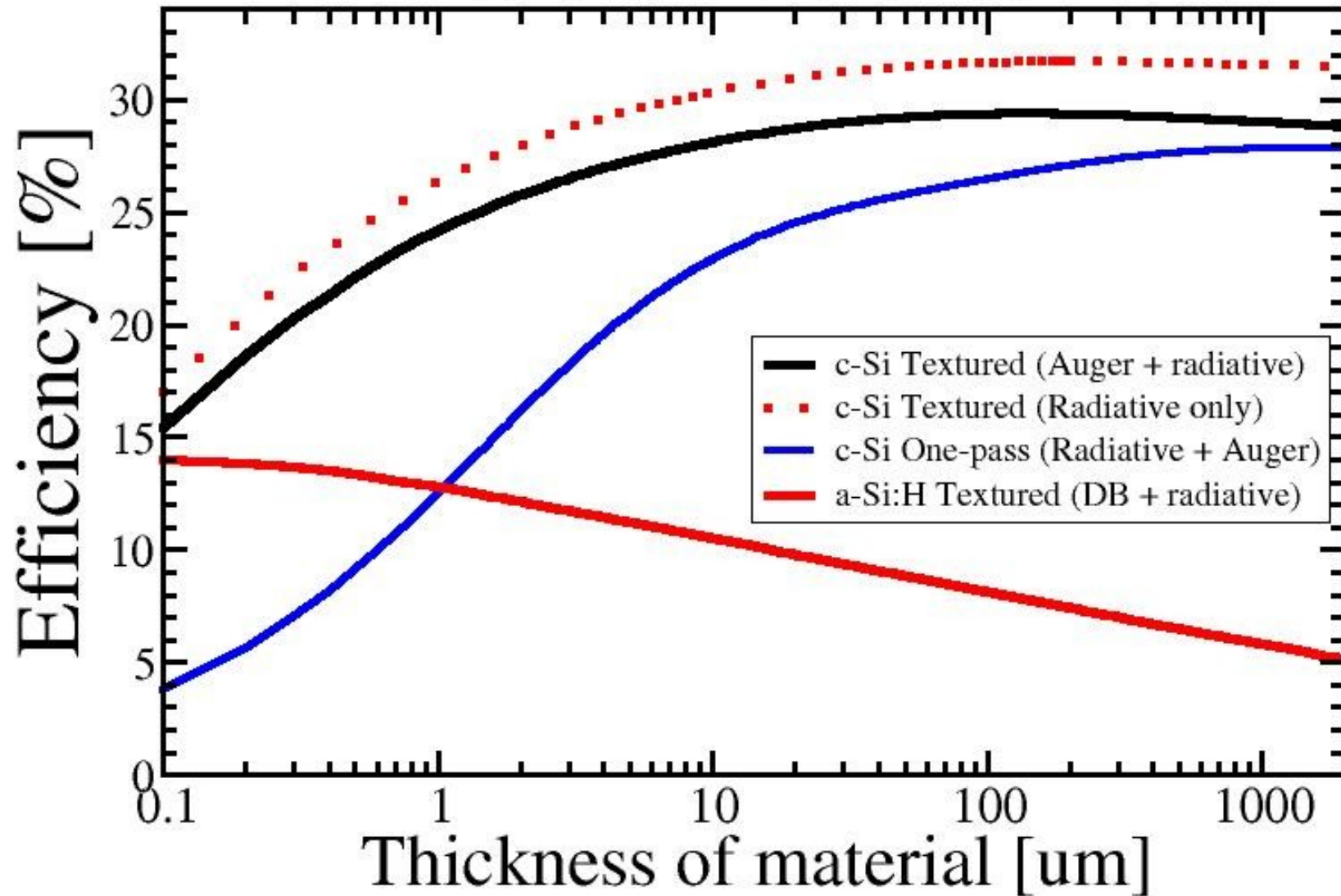
Radiative recombination-limited efficiency of solar cells AM1.5G (0.1 W/cm²)



Optical Absorption Coefficient as function of energy



Efficiency as function of thickness



- $C=C_n+C_p=3.88 \cdot 10^{-31} \text{ cm}^{-6} \text{ s}^{-1}$ (Auger, c-Si)
- $R_{DB} = 4 \cdot 10^4 \text{ cm}^{-3} \text{ s}^{-1}$ (recombination in mid gap states, a-Si:H)

Theoretical limits: partial conclusions

- In case of c-Si there is a full knowledge of all loss mechanisms, but only radiative and Auger recombinations are enable since all other losses can be reduced by improving the design of the device .
- In case of a-Si:H not all recombination models were included in this analysis and what is not currently defined is the contributions of each loss mechanism
- By considering the I_{sc} limit (22.43 mA/cm²) and the solar cell fabricated in laboratory (up to $I_{sc}=17$ mA/cm²), a substantial gain in short circuit current can therefore still be obtained by improving the light trapping.

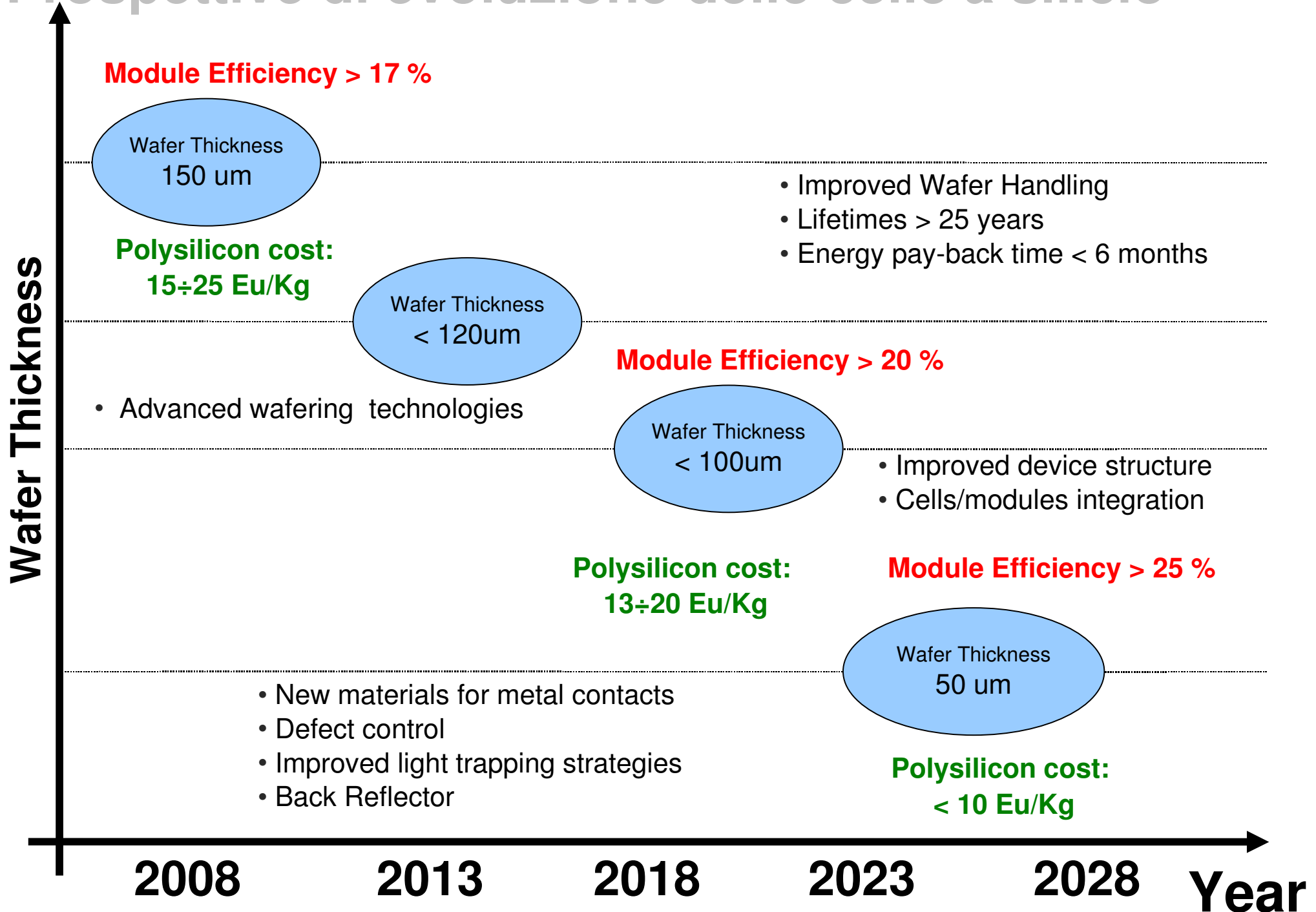
Theoretical limits: partial conclusions

- In terms of efficiency, for a-Si:H the performance record (9% single junction, 12% tandem, 13% triple junction) is still too far from the upper limit (28%) and most of this gap is due to poor material quality (defects, enhanced recombinations in intrinsic layers).
- The different optical absorption profile of a-Si:H compared to c-Si allows to design very thin slabs of absorbing material.
- The efficiency degradation (“Staebler-Wronski effect”) is not included in this analysis.
- The analysis was performed with the p-n junction electrical model, but a-Si:H devices use p-i-n configuration.

Silicon solar cells

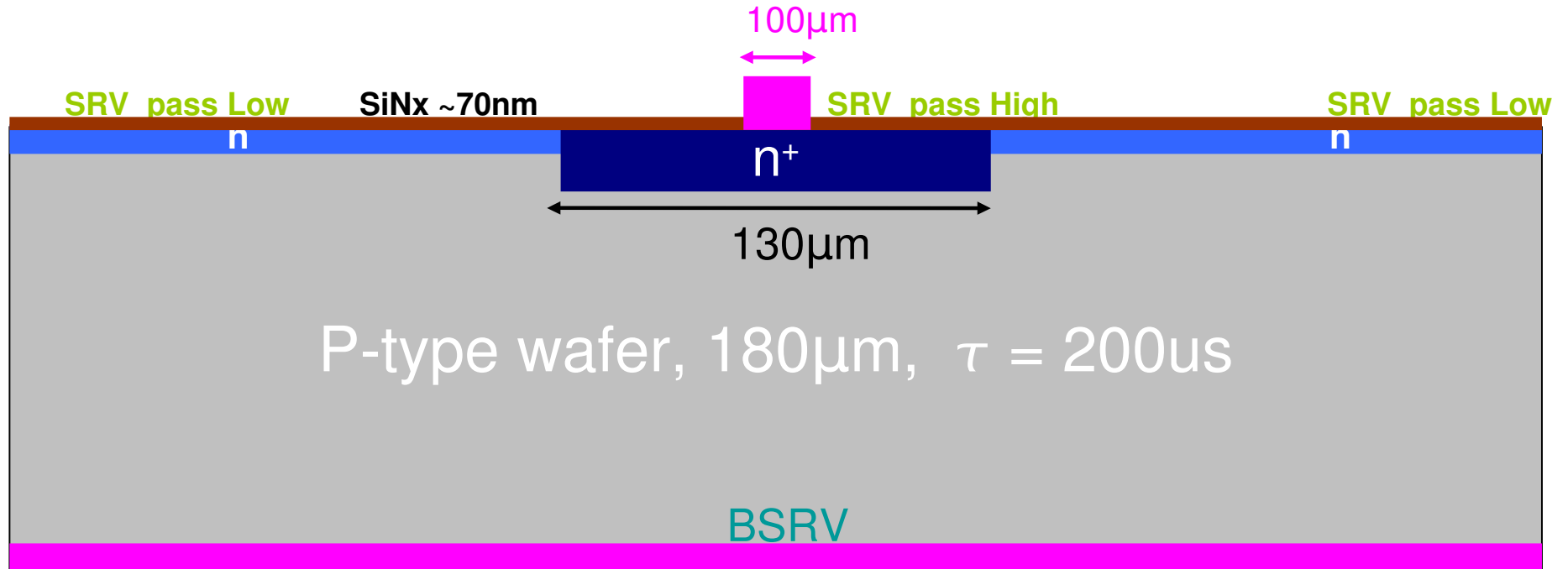
- Crystalline solar cells
 - low defect density.
 - low recombination rates
 - η : 15% - 20%
- Amorphous-Si (thin film) solar cells
 - cheaper
 - thinner and lighter
 - η : 7% - 10% (large recombination rate)

Prospettive di evoluzione delle celle a silicio



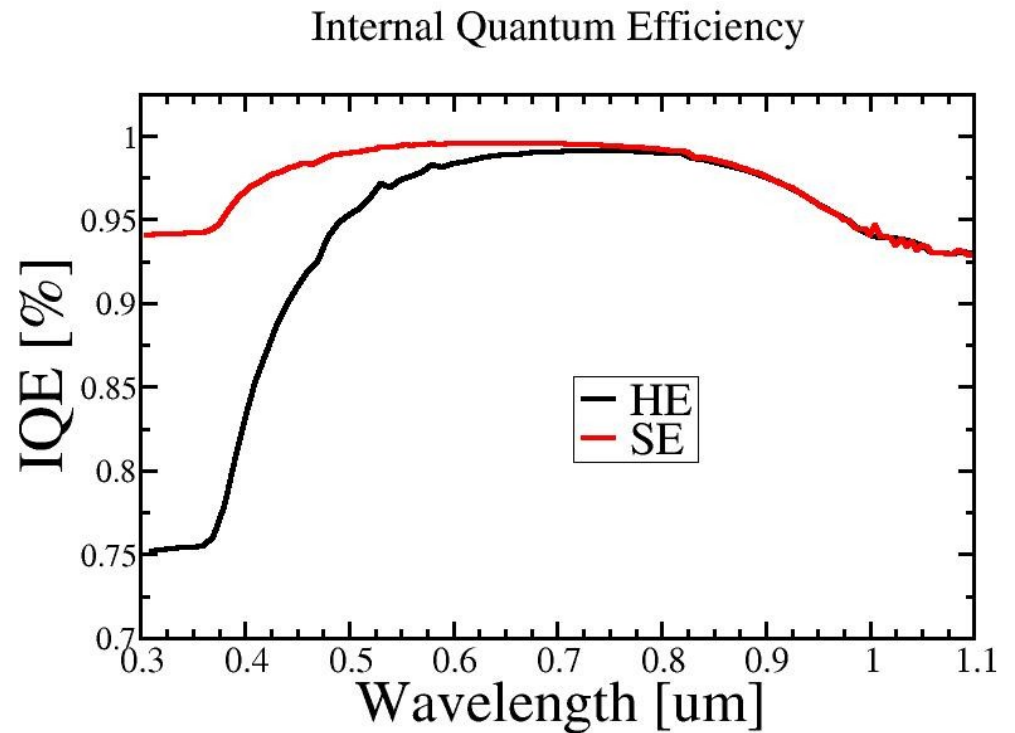
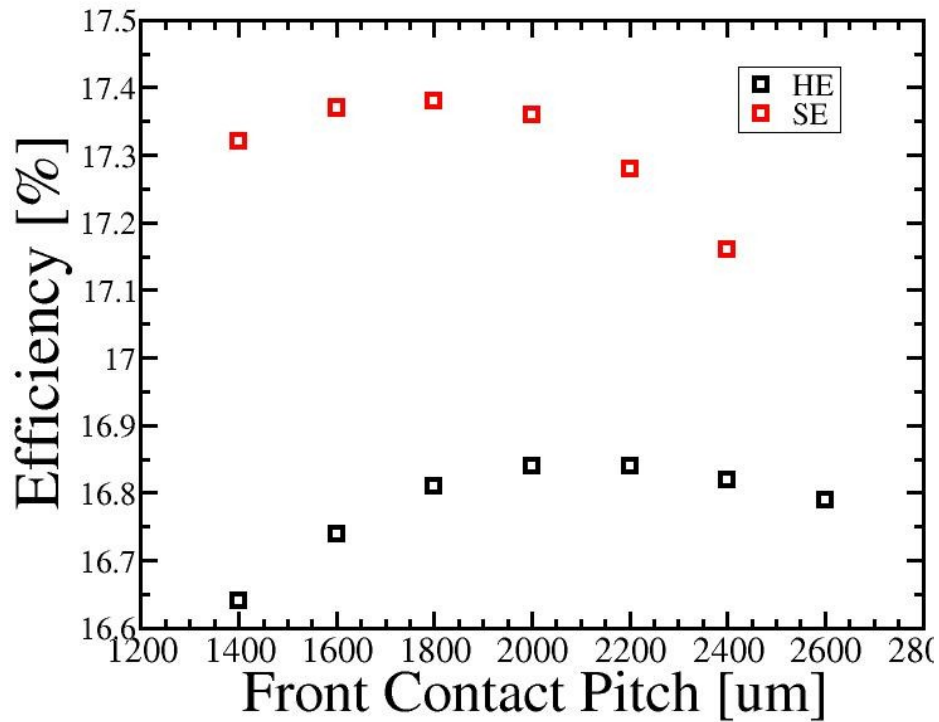
Advanced c-Si Solar Cells: Selective Emitter

Selective Emitter



- Deep n⁺ diffusion under front metalization ($10 \Omega \square \square$.
- N-type diffusion between finger ($117 \Omega \square \square$.
- P-Type bulk ($\rho = 1.33 \Omega \square \text{ cm}$ $1 \text{e}16 \text{ cm}^{-3}$)
- Contact resistance $1 \text{m}\Omega \cdot \text{cm}^2$

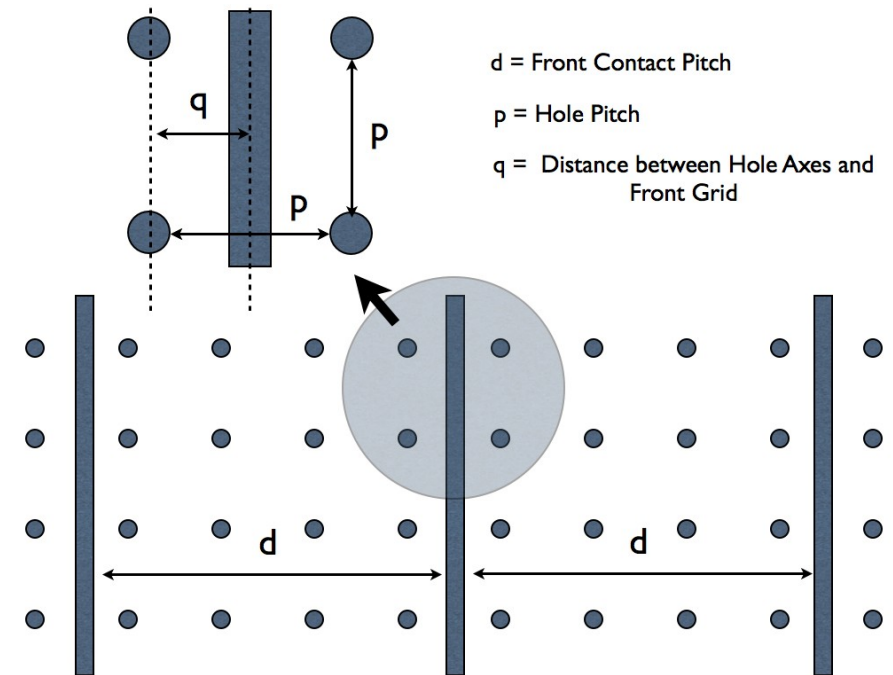
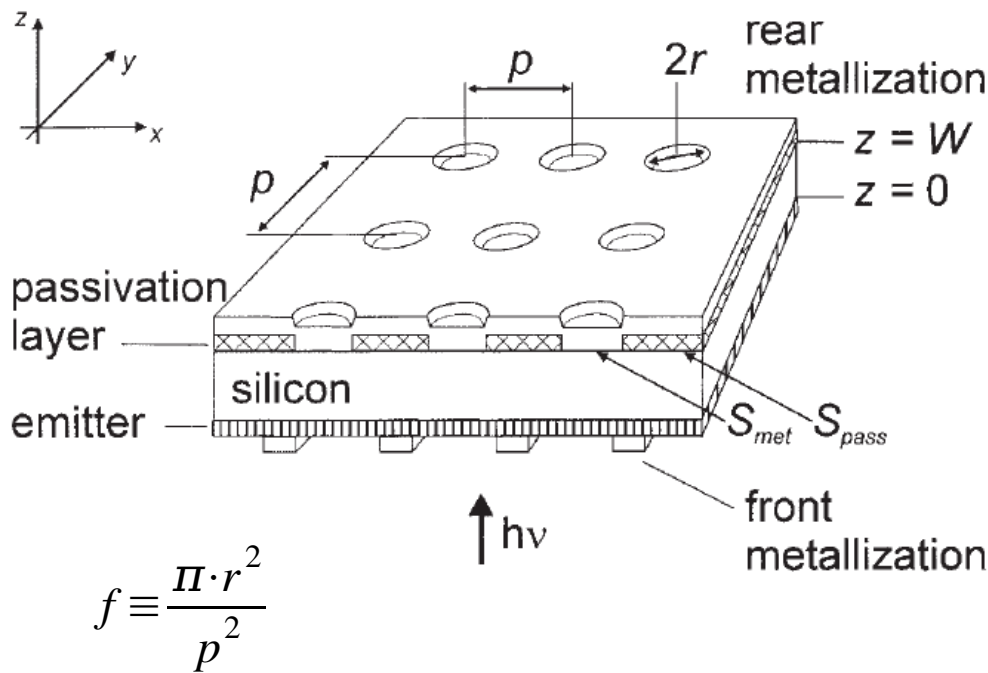
Selective Emitter (SE) vs Homogeneous (HE)



- **HE: max Eff at 2000 um ($\eta=16.84\%$, $V_{oc}=0.611V$, $FF=0.803$, $J_{sc}=34.1 \text{ mA/cm}^2$)**
- **SE: max Eff at 1800 um ($\eta=17.38\%$, $V_{oc}=0.621V$, $FF=0.795$, $J_{sc}=35.1 \text{ mA/cm}^2$)**
 - **SE+ Auger recombination**
 - **SE+ Surface recombination (between fingers)**
 - **SE+ Better Blue response**
 - **SE- Emitter Resistance**

Advanced c-Si Solar Cells: Local Point

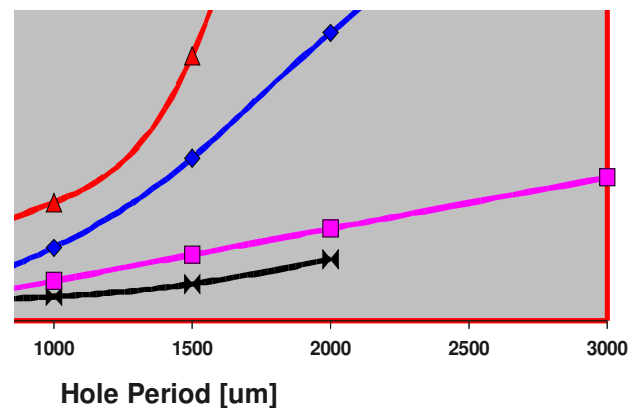
Local Point Solar Cell



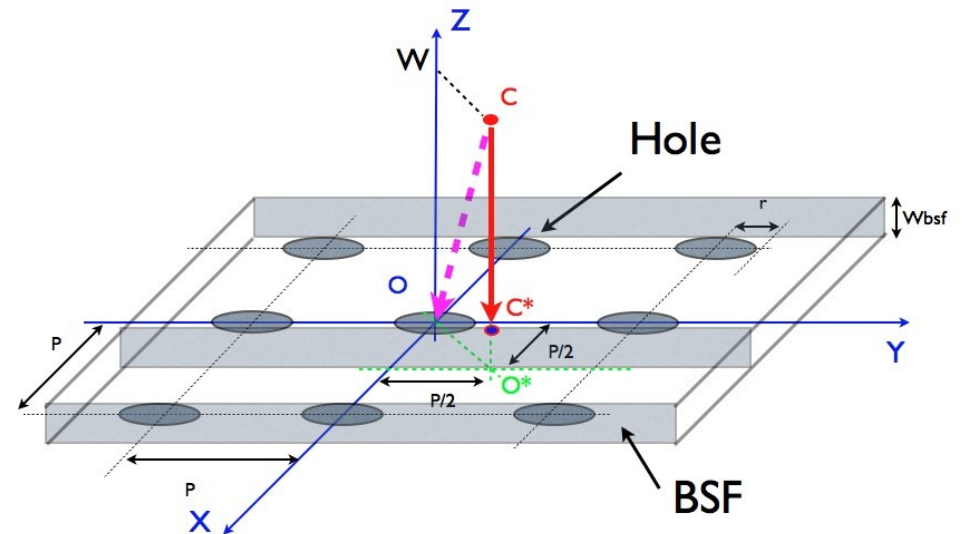
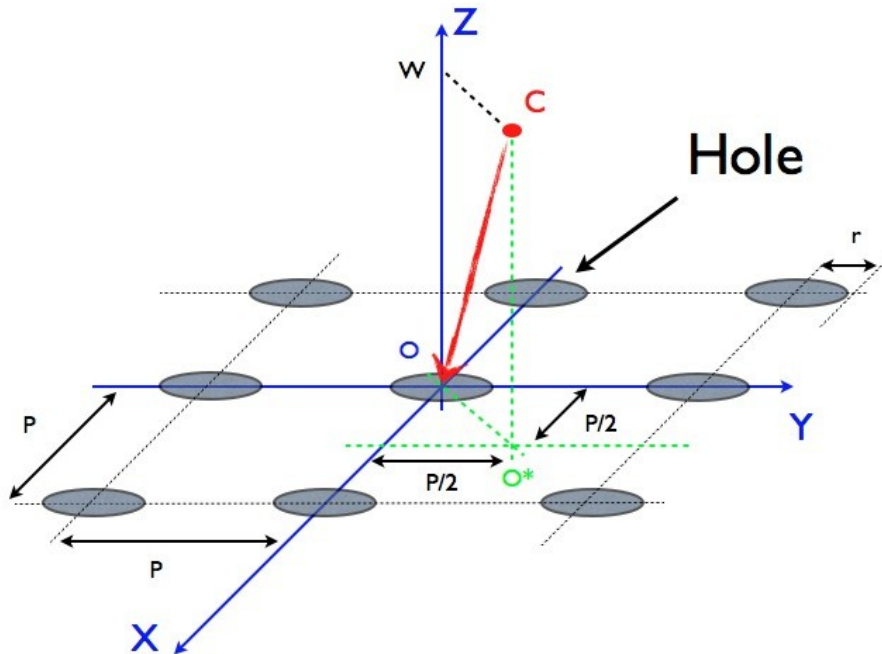
- Expected advantage (compared to a conventional full back contact cell):
 - Reduced back surface recombination velocities (BSRV)
- Trade-off between the metalization fraction f and efficiency (a reduced metalization factor would increase the effective base resistance $R_{s,eff}$)

Local Point Solar Cell analysis strategy

- Evaluation of the effective base series resistance $R_{s,eff}$ and of the effective back surface recombination velocity S_{eff} by using an analytical semi-empirical model.
- 1D (fast) simulation to find the range of interest of the geometrical parameters (p, r, f) in order to maximize the efficiency of the device.
- Validation of the results by simulating the device with a 3D structure (Sentaurus).



Local Point Solar Cell with BSF



- W = wafer thickness
- W_{BSF} = BSF layer thickness
- Majority carrier path length $LC_{bsf} = |C^*-C| + |O^*-C^*| + |O-O^*|$
- Since BSF is heavily doped, $LC_{bsf} \approx |C^*-C| < LC_{no_bsf}$

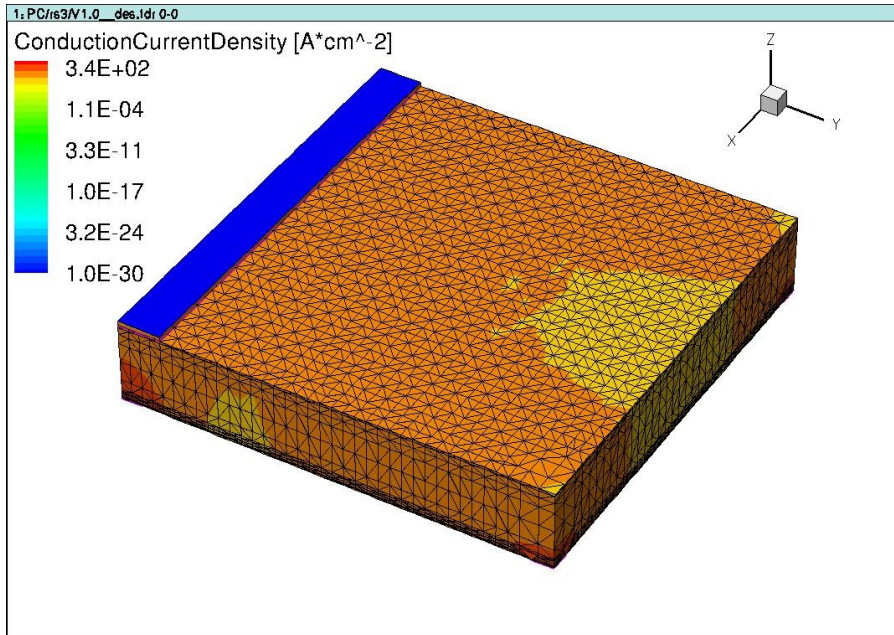
$$R_{s,eff}^{W/OBSF} = f(\rho, W, P, R) \rightarrow R_{s,eff}^{W/BSF} = f\left(\rho, \frac{W}{\alpha}, P, R\right)$$

$$\alpha = \sqrt{\left(1 + \frac{P^2}{2 \cdot (W - W_{BSF})}\right)} > 1$$

Local Point Solar Cell:

3D simulation and validation of the model to evaluate the effective base series resistance

Preliminary results



Hole Pitch	Hole Size	Analytical Model	Sentaurus 3D
p	s=2r	$R_{s,eff}$	$R_{s,eff}$
[μm]	[μm]	$\text{m}\Omega \cdot \text{cm}^2$	$\text{m}\Omega \cdot \text{cm}^2$
200	100	40	160
1000	100	610	671
1000	200	280	385

No contact resistance assumed.

Front contact pitch = 2000 μm

Wafer thickness = 185 μm

Wafer resistivity = 1.33 $\Omega \cdot \text{cm}$, no BSF